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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Priority Application Serial No. 10/128,933
Priority Filing Date April 23, 2002
Inventor Werner Juengling
Assignee Micron Technology, Inc.
Priority Group Art Unit 2822
Priority Examiner J.L. Brophy
Attorney's Docket No. MI22-2391
Title: Semiconductor Processing Methods Of Forming A Contact Opening To A
Conductive Line and Methods of Forming Substrate Active Area
Source/Drain Regions

PRELIMINARY AMENDMENT

To: Mail Stop Patent Application
Commissioner for Patents
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Sir:

This is a preliminary amendment accompanying a Request for Continuation Application for the above-entitled patent application. Prior to examining the application, please enter the following amendments.

AMENDMENTS

Underlines indicate insertions and ~~strikeouts~~ indicate deletions.